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Local order structure and surface acidity properties of a Nb₂O₅/SiO₂ mixed oxide prepared by the sol-gel processing method

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Abstract

The sol–gel processing method was used as an alternative route to obtain Nb₂O₅ phase homogenously dispersed in the SiO₂ matrix, improving the thermal stability of the Brønsted acid sites, Nb–OH and Nb–OH–Si groups. The local niobium structure and the influence of the amount of niobia on the surface of the Nb₂O₅/SiO₂ system were studied by XAS and XPS, respectively. For the samples calcined at 423 and 873 K, the $3d_{5/2}$ BE values are at ca. 208.2 eV, indicating an ionic character for Nb(V) species in the SiO₂ matrix, probably associated to Si–O–Nb linkages. The features of Nb K-edge XANES spectra of samples show the absence of Nb=O species. The Nb K-edge EXAFS oscillations exhibit a shoulder at ca. 5.6 Å⁻¹, which probably arises from Nb–O–Si. This fact corroborates the EXAFS simulation data of the second coordination shell, whose best fitting is achieved with three distances, two Nb–Nb lengths and one Nb–Si.

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Keywords: Niobia supported in silica; Sol-gel processing method; XAS; XPS; Acid sites

1. Introduction

Many catalytic applications for a highly dispersed Nb₂O₅ phase on the SiO₂ surface, obtained by the grafting process, have been described [1–9]. The preparations procedures consist in reacting a precursor reagent of the metal oxide with the \equiv SiOH group on the SiO₂ surface and formation of a monolayer film adhered onto a substrate surfaces by means of Si–O–Nb bond formation [10–12]. The Lewis and Brønsted acid densities on the surface have been monitored by controlling the amount and degree of dispersion of the metal oxides adhered onto the surface since such characteristics may have a great influence on the catalytic performance of these materials [13–15].

As an alternative procedure, the sol-gel processing method has been used to homogeneously disperse Nb_2O_5 phase in the SiO₂ matrix [16]. In this case niobium oxide, different from what is found adhered on a silica matrix obtained by the grafting method, is

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dispersed in the bulk of the SiO₂ matrix as aggregated nanosized particles. In this way, the Nb₂O₅ particles are confined inside the SiO₂ matrix conferring low mobility to them, even upon heating the mixed oxide solid at high temperatures [17]. Therefore, the local structure for Nb₂O₅ obtained by the sol–gel processing method can be different, when compared with the bidimensional oxide monolayer obtained by the grafting process.

The Nb₂O₅ particles in the sol–gel matrix, as revealed by transmission electron microscopy [17], show a phase transition depending on the amount of the metal oxide present in the matrix, becoming crystalline upon heating above 1000 K, while the SiO₂ matrix remains amorphous even when heating at temperatures as high as ca. 1473 K.

Therefore, for a solid obtained by the sol-gel processing method, a more detailed investigation to characterize such systems as obtained is required since the observed acid properties depend on the local niobium oxide structure. Aiming to obtain such information in the present work, the dynamics of the structural changes of the Nb₂O₅/SiO₂ system were obtained using X-ray photoelectron spectroscopy

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(XPS) and X-ray absorption spectroscopy (XAS). The nature of the acid sites was investigated by Fourier transform infrared (FT-IR spectroscopy) with pyridine as molecular probe. The overall findings are then correlated with the thermal stability of the Lewis and Brønsted acid sites. The results were obtained for different niobium oxide amounts in the silica and for different treatment temperatures.

2. Experimental

2.1. Samples preparations

The sol-gel method was employed to prepare $Nb_2O_5/$ SiO₂ samples according to the following procedure [17]. Tetraethylorthosilicate (TEOS, Aldrich) was mixed with dry ethanol in the molar proportion TEOS: EtOH = 1: 3.8. To 50 cm³ of this solution, 0.86 cm³ of concentrated HCl solution was added and then the solution was refluxed for 2.5 h. The resulting solution is designated as solution A. Another solution, called B, was prepared by dissolving high purity solid NbCl₅ (from Companhia Brasileira de Metalurgia e Mineração, CBMM) in 50 cm³ of dry ethanol (concentrations 0.22, 0.45, and 0.67 mol L^{-1}). These solutions were allowed to react under a N2 atmosphere until production of gaseous HCl was not detected. At this stage, practically all Nb is in the Nb(OEt)₅ form. Solution B was added to solution A and the mixtures were stirred at room temperature for 3 h. After this time, 140 cm^3 of H₂O was slowly added to the mixture followed by stirring at room temperature for 2h. Finally, the mixture was allowed to rest at 333 K until complete gelation. The solids were washed several times with water and finally with dry ethanol. The residual solvent from the xerogels was evaporated at 383 K for 24 h, and the solid materials were ground and sieved to 200 mesh. The final materials Nb_2O_5/SiO_2 (2.5, 5.0, and 7.5 as Nb_2O_5 mol percentage with respect to silica) were calcined in the temperature range between 423 and 1273 K.

The powdered samples thus prepared were designated as 2.5% Nb₂O₅/SiO₂, 5.0% Nb₂O₅/SiO₂, and 7.5%Nb₂O₅/SiO₂. Commercial amorphous SiO₂ (Fluka) and Nb₂O₅ (CBMM) were used in specific investigations.

2.2. XPS study

The XPS analysis was performed using a VSW HA-100 Spherical Analyzer, with an Al ($K\alpha$ line, hv = 1486.6 eV) X-ray source. The high-resolution spectra were measured with constant analyzer pass energy of 44 eV, which produces a FWHM line width of 1.8 eV for the Au $4f_{7/2}$ line. The powdered samples were pressed into pellets and fixed to a stainless steel sample holder with double-faced tape and analyzed without further preparation. The binding energies were referenced to an adventitious C 1s line at 284.6 eV. Prior to curve fitting with Gaussian line shapes, a linear background was subtracted from the data. The atomic compositions were obtained from the C 1s, O 1s, Si 2p, and Nb 3d peak areas, using cross sections for photo-ionization from the literature [18].

2.3. XAS analyses

The XAS measurements at room temperature were done at XAFS beam line of National Synchrotron Light Laboratory (LNLS) in Campinas (ring energy of 1.37 GeV and beam current about 175 mA). The X-ray absorption near-edge spectroscopy (XANES) and X-ray absorption fine structure (EXAFS) spectra for the calcined samples were obtained and, for comparison, the spectrum for amorphous niobia was also acquired.

The monochromator was double crystal Si (220) and the incident and transmitted photon intensities were determined by means of standard ion chamber detectors. The energy steps were 0.8 eV for the XANES region. For the EXAFS region, five scans were acquired for each sample with steps of 2.0 eV. The energy ranges were 18,920–19,250 and 18,920–19,600 eV for XANES and EXAFS regions, respectively. The EXAFS data analyses were done by a standard procedure of data reduction, using the computational program CDXAS [19]. The curve-fitting analysis was performed by using theoretical phase shifts and amplitude functions from the simple pair Nb–O, and from Nb foil (ICSD file 76554) [20] and NbSi₂ (ICSD file 16502) [21], which were calculated by the FEFF7.0 computational program.

2.4. Infrared spectroscopy study

The Lewis and Brønsted acid sites of the pre-calcined samples (383 K) were investigated after pyridine adsorption for 15 min, with subsequent drying under low pressure ($\sim 10^{-5}$ Pa for 30 min) at different temperatures (298–523 K). The Fourier transform infrared spectra (FT-IR) were obtained as pressed disks in the range of 1650–1400 cm⁻¹, using a Bomem MB-Series instrument. For comparison, the FT-IR spectra of pyridine adsorbed on a silica surface were acquired following the same procedure as described above.

3. Results and discussion

3.1. XPS analyses

Nb 3*d* X-ray photoelectron spectra for 2.5% Nb₂O₅/SiO₂, 5.0% Nb₂O₅/SiO₂, and 7.5% Nb₂O₅/SiO₂ samples, calcined at 423, 873, and 1273 K, are presented in

Fig. 1. Table 1 lists the corresponding binding energy (BE values) and the Nb/Si atomic percentage.

The O 1s BE peaks at 532.8 and 531.0 eV, for oxygen bonded to Si and Nb atoms, respectively, do not change with the thermal treatment and with the different compositions of the Nb_2O_5/SiO_2 system. The first value



Fig. 1. Nb 3d X-ray photoelectron spectra recorded for the: (a) 2.5% Nb₂O₅/SiO₂; (b) 5.0% Nb₂O₅/SiO₂; and (c) 7.5% Nb₂O₅/SiO₂ samples calcined at 423, 873, and 1273 K.

Table 1

XPS BE values as a function of Nb-content and temperature of thermal treatment for the Nb_2O_5/SiO_2 system and Nb/Si atomic percentage

Samples	BE (eV)				
	Nb 3 <i>d</i> _{5/2}	Si 2p	O 1 <i>s</i>		(
			Si–O	Nb–O	
T = 423 K					
2.5% Nb ₂ O ₅ /SiO ₂	208.5 (2.4) ^a	103.6 (2.5)	532.9	531.0	3
5.0% Nb ₂ O ₅ /SiO ₂	208.3 (2.6)	103.5 (2.5)	532.8	530.9	6
7.5% Nb ₂ O ₅ /SiO ₂	208.0 (2.4)	103.4 (2.4)	532.8	531.0	8
$T = 873 \mathrm{K}$					
2.5% Nb ₂ O ₅ /SiO ₂	208.0 (2.7)	103.4 (2.5)	532.7	531.0	3
5.0% Nb ₂ O ₅ /SiO ₂	208.3 (2.6)	103.6 (2.5)	532.6	530.9	7
7.5% Nb ₂ O ₅ /SiO ₂	208.0 (2.3)	103.6 (2.3)	532.9	531.0	7
$T = 1273 \mathrm{K}$					
2.5% Nb ₂ O ₅ /SiO ₂	207.6 (2.8)	103.7 (2.5)	532.8	531.0	3
5.0% Nb ₂ O ₅ /SiO ₂	207.3 (2.4)	103.5 (2.5)	532.9	531.1	3
7.5% Nb ₂ O ₅ /SiO ₂	207.7 (2.4)	103.7 (2.5)	532.7	530.8	4

^a(FWHM)=full-width at half-maximum.

obtained is the same observed for O 1s bulk phase in SiO₂ gel and the second one in Nb₂O₅ [22–25]. Similarly, Si 2p BE peak values, observed at 103.6 eV, are the same for the three compositions and after the thermal treatments [24,25].

The two spin-orbit components, Nb $3d_{5/2}$ and $3d_{3/2}$ BE peaks, change depending on the thermal treatment of the samples. For the samples calcined at 423 and 873 K, the $3d_{5/2}$ BE values remain practically unchanged at ca. 208.2 eV. After heating the samples at 1273 K, the BE peaks shift to a lower energy region, i.e., ca. 207.5 eV. This value is the same as that exhibited by bulk Nb₂O₅, where $3d_{5/2}$ BE is observed at 207.5 eV with multiplet splitting of 2.5 eV [26-29]. The BE shift is associated with a decrease of the Nb atom ionic character upon heat treatment. This behavior can be explained by taking into consideration that the niobium atoms are highly dispersed in the matrices and attached to the silica by Si-O-Nb bonding, whose origin occurred during the condensation process of the sol-gel matrix [30]. Upon the higher temperature, 1273 K, the metal oxides segregate and agglomerate into larger particles, with breaking of Si-O-Nb bonds, and the observed BE is that of bulk phase Nb₂O₅ calcined at 1273 K [31]. The ionic character of Nb atoms in the Nb₂O₅/SiO₂ system calcined at lower temperatures is similar to the atoms in NbCl₅, whose $3d_{5/2}$ BE value is 208.2 eV [29].

Table 1 shows the Nb/Si atomic percentage probed by the XPS technique. The amount of the Nb atoms on the surface does not change significantly for samples heated up to 873 K, indicating that the oxide particles are not thermally mobile. This behavior is a consequence of the highly and well-dispersed character of the niobia species in the SiO₂ matrix. For samples calcined at 1273 K, the metal amount on the surface showed a significant decrease. This fact can be noted by the observation of the Nb/Si atomic ratios that decrease from 6% to 3% for 5.0% Nb₂O₅/SiO₂ sample and from 8% to 4% for 7.5% Nb₂O₅/SiO₂ sample. For 2.5% Nb₂O₅/SiO₂ sample, the Nb/Si ratio does not change because, in this case, the niobium oxide particles are much more dispersed and the crystalline particle sizes are also much smaller. It must be remembered that SiO₂ in every case

3.2. XAS analyses

The Nb K-edge XAS spectra and the corresponding structural parameters for 2.5% Nb₂O₅/SiO₂, taken as a representative sample, were obtained. Fig. 2 presents the Nb K-edge XANES spectra obtained for samples calcined at 423, 573, and 873 K, and for pure Nb₂O₅ as reference (amorphous phase).

remained amorphous, as was shown by XRD and

transmission electron microscopy images [17].

Independent of the thermal treatment, the niobium species in the samples and in the reference exhibit very similar XANES features: a not well-defined pre-edge adsorption and two peaks in the post-edge region. The pre-edge peak is due to the s-d transitions and the intensity depends on the coordination, being low for octahedral [16]. Some authors have assumed that the absence of this peak is attributed to the lack of a Nb=O bond on the silica surface, which is due to tetracoordinated niobia species [16,32] or, as is known for heavy elements like niobium, sometimes the internal transitions responsible for the peaks in the pre-edge are so weak that they do not appear clearly in the XANES spectrum.

Fig. 3(A) presents the Nb K-edge EXAFS spectra of the samples calcined at 423, 573, and 873 K, and of pure



Fig. 2. Nb K-edge XANES spectra from 2.5% Nb₂O₅/SiO₂ samples calcined at: (a) 423 K, (b) 573 K, and (c) 873 K, and from pure Nb₂O₅ (amorphous phase).

A Nb₂O₅ EXAFS signal $k^3 * \chi(\kappa)$ (b) (a) 3 4 5 6 8 9 10 11 12 k/Å⁻¹ Magnitude of the Fourier transform (a.u.) $\pmb{\mu}$ Nb₂O (c) (b) (a) 0.0 3.0 0.5 2.5 3.5 1.0 1.5 2.0 4.0 R/Å

Fig. 3. Nb K-edge EXAFS spectra (A) from 2.5% Nb₂O₅/SiO₂ sample calcined at (a) 423 K, (b) 573 K, and (c) 873 K, and from the pure Nb₂O₅ (amorphous phase), and the respective Fourier transforms of the Nb K-edge EXAFS (B) in the *k* range of $3.00-12.00 \text{ Å}^{-1}$.

Nb₂O₅. The EXAFS oscillations of the sample, calcined at different temperatures, exhibit a shoulder at ca. 5.6 Å^{-1} when compared to the pure Nb₂O₅ spectrum, this peak is attributed to the interference of the backscattered electron wave by the silicon atom at ca. 3.30 Å [33].

The magnitudes of the Fourier transforms of Nb Kedge EXAFS spectra (denoted as |F(r)|) in the k range of 3.00–12.00 Å⁻¹ for the sample calcined at 423, 573, and 873 K, and for pure Nb₂O₅ (amorphous phase) are presented in Fig. 3(B). The static disorder of the oxygen around the niobium is responsible for the rapid fall to low frequency EXAFS oscillations, creating beats that lower the amplitude of the total signal, together with a broad low-*r* peak in the Fourier transform for crystallite Nb₂O₅ and Nb₂O₅ dispersed in glass [34,35].

For niobia in the H crystallographic phase, the Nb–O first neighbor bond lengths are found around three values, 1.82, 1.97 and 2.24 Å, with average coordination

numbers 1.6, 3.0 and 1.2, respectively [33,36]. As a consequence of this large range of Nb–O distance distributions (low crystalline symmetry of Nb₂O₅), the interference of the backscattered electron waves has a highly destructive degree, leading to more non-defined peaks in the |F(r)| for the corresponding region [34]. For this reason the |F(r)| in the region related to the peaks of first neighbor backscattering (0.5–2.2 Å), for both the sample and the reference compound, is less structured.

The distances, the coordination numbers and the Debye–Waller factors (denoted R, N, and σ , respectively) of the first coordination shell Nb–O (distances between 0.5 and 2.2 Å) were determined by curve-fitting analyses for the samples calcined at 423, 573, and 873 K (see Table 2), Fig. 4(A) presents experimental (dot) and simulated (solid line) curves. A simple Nb–O pair was taken to achieve the theoretical phase shift and amplitude function to simulate the EXAFS data, making use of the FEFF7.0 computational program.

The best-fit results for the first coordination shell were obtained taking in consideration the presence of three distances (types of Nb–O bond) for both the sample (independent of its thermal treatment) and for pure Nb_2O_5 (see Table 2). No difference in the structural parameters for the sample calcined at different temperatures can be noted and the lengths of the Nb–O bonds and their, respectively, coordination numbers do not change substantially.

The comparison between the structural parameters obtained for pure Nb₂O₅ and those obtained for the sample shows some differences in the Nb–O bond distances: all three Nb–O bond lengths are longer for pure Nb₂O₅, 1.76, 1.98, and 2.25 Å, and the respective coordination numbers, 2.4, 3.2 and 0.6, sum to 6. We also can note that the corresponding Debye–Waller factors are higher for pure Nb₂O₅, suggesting a higher disorder of the local structure of non-supported Nb₂O₅ than that for the 2.5% Nb₂O₅/SiO₂ sample.

For the second niobium coordination shell (distances between 2.7 and 3.8 Å), in the |F(r)| of pure Nb₂O₅ it is possible to distinguish two peaks centered at ca. 3.0 and 3.5 Å. These peaks are due to the backscattering of niobium (second neighbor). For the samples calcined at



Fig. 4. Comparison between the filtered signal (line) and the related fit (dot) for 2.5% Nb₂O₅/SiO₂ samples calcined at (a) 423 K, (b) 573 K, and (c) 873 K: (A) first coordination shell (Nb–O) and (B) second coordination shell (Nb–Nb).

Table 2

Curve fitting analyses of Fourier transforms of Nb K-edge EXAFS data for the 2.5% Nb₂O₅/SiO₂ sample calcined at 423, 573, and 873 K and for reference Nb₂O₅

T (K)	Nb–O			Nb–O			Nb-O		
	$N(\pm 0.3)$	R (Å) (±0.03)	σ (Å) (±0.02)	$N(\pm 0.3)$	R (Å) (±0.03)	$\sigma (\rm \AA) ~(\pm 0.02)$	$N(\pm 0.3)$	R (Å) (±0.03)	σ (Å) (±0.02)
423	1.0	1.69	0.08	2.1	1.93	0.03	0.5	2.17	0.06
573	1.2	1.69	0.03	2.1	1.88	0.06	1.1	2.10	0.06
873	1.4	1.70	0.09	2.3	1.90	0.07	0.5	2.18	0.05
Nb ₂ O ₅	2.4	1.76	0.14	3.2	1.98	0.16	0.6	2.25	0.07
	Nb–Nb			Nb–Si			Nb–Nb		
423	1.0	3.16	0.12	1.0	3.39	0.08	2.1	3.72	0.10
573	1.4	3.24	0.13	1.0	3.39	0.09	2.5	3.76	0.07
873	1.3	3.26	0.16	1.4	3.37	0.07	3.0	3.69	0.08
Nb ₂ O ₅	1.8	3.19	0.11	_	—	—	4.3	3.85	0.12

different temperatures, the |F(r)| present peaks at ca. 3.0 Å, whose intensity does not depend on the treatment temperature. Otherwise the intensities of the second peak (ca. 3.5 Å) increase with the thermal treatment. In order to understand this behavior, the second coordination shell had the structural parameters obtained as presented in Table 2. Fig. 4(B) presents the experimental and simulated curves. The best fit of the EXAFS data for the sample calcined at different temperatures was achieved when we assumed three-wave fitting for the simulation of this region, Nb-Nb, Nb-Si, and Nb-Nb. The theoretical phase shift and amplitude function used for the calculations of the structural parameters were extracted from Nb foil (ICSD file 76554) [20] and from NbSi₂ (ICSD file 16502) [21] compounds, also making use of the FEFF7.0 computational program. For pure Nb₂O₅, the fitting is satisfactory with only two distances with Nb-Nb lengths at 3.19 and 3.85 Å with a total coordination number around 6. Meanwhile for the sample, the best fit is achieved with three distances, two Nb-Nb lengths and an additional one for the Nb-Si length [32]. The samples calcined at 573 and 873 K present higher Nb-Nb distances compared to that obtained for the pure niobia, at 3.24 and 3.26 Å, and all the samples presented smaller coordination numbers, 1.0, 1.4, and 1.3, respectively. The coordination numbers related to the Nb–Si distances (3.39, 3.39, and 3.37 Å) do not change with increasing temperature, being maintained at 1.0, 1.0, and 1.4. Nevertheless, the coordination numbers related to the longer Nb-Nb distances (3.72, 3.76, and 3.69 Å) increase from 2.1 to 2.5 and 3.0, and are shorter than the presented by the pure niobia, when the sample is calcined at 573 and 873 K, respectively. Besides the presence of the two or three Nb-O lengths, the Nb-Si lengths also have been considered in the simulations for the second niobium coordination shell in Nb₂O₅/SiO₂ material. The shorter Nb-O distance has been associated to the Nb-O-Si linkage and the longer Nb–O distance to the Nb–O–Nb linkage [33,37].

3.3. Study of surface acidity

Fig. 5 shows the FT-IR spectra obtained for 2.5% Nb₂O₅/SiO₂, 5.0% Nb₂O₅/SiO₂ and 7.5% Nb₂O₅/SiO₂ samples after adsorption of pyridine followed by the thermal treatment at 383 K under low pressure $(\sim 10^{-5} \text{ Pa})$. The FT-IR spectra obtained, independent of the amount of Nb₂O₅ loading, present the same band positions, except for their intensities, which are slightly higher for matrices presenting higher amounts of the metal oxide. Thus, for estimation of the thermal stability of the acid sites only the vibrational spectra results for 2.5% Nb₂O₅/SiO₂ sample were considered.

Fig. 6 shows the FT-IR spectra obtained after adsorption of pyridine followed by heat treatment

Fig. 6. FT-IR spectra of pyridine adsorbed on the 2.5% Nb₂O₅/SiO₂ sample under low pressure ($\sim 10^{-5}$ Pa for 30 min) at (a) room temperature, (b) 323 K, (c) 373 K, (d) 423 K, (e) 473 K, and (f) 523 K and on pure SiO₂ after the same treatment at room temperature.



1650 1625 1600 1575 1550 1525 1500 1475 1450 1425 1400 Wave number/cm⁻¹

Fig. 5. FT-IR spectra of pyridine adsorbed on: (a) 2.5% Nb₂O₅/SiO₂; (b) 5.0% Nb₂O₅/SiO₂; and (c) 7.5% Nb₂O₅/SiO₂ samples under low pressure ($\sim 10^{-5}$ Pa for 30 min) at room temperature.



between 298 and 523 K, under low pressure. For comparison, Fig. 6 also presents a spectrum of pure SiO_2 with adsorbed pyridine molecules submitted to $\sim 10^{-5}$ Pa at 298 K. The FT-IR spectra are limited in the wavenumber range between 1650 and 1400 cm⁻¹, where normal pyridine vibrational modes of interest are observed.

The bands at 1599 and 1448 cm⁻¹ (Fig. 6(a)–(e)) are due to the 8*a* and 19*b* mode of pyridine bonded to the free silanol groups, \equiv SiOH, through hydrogen bonding [37,38]. This band is also observed for pure SiO₂ treated at room temperature under 10⁻⁵ Pa.

The band observed at 1545 cm^{-1} for the samples heated between 298 and 523 K (Figs. 6(a)-(f)), is due to the 19b mode of pyridine molecules on a Brønsted acid site [10,39–41]. It is known that in pure Nb₂O₅ the Brønsted acid sites are thermally unstable at room temperature [42] but in the present case, for metal oxide in the sol-gel matrix, the thermal stability is considerably improved. This acid site is due to the OH groups attached to both groups, Nb-OH and also to Nb-OH-Si bridging [43], since for pure SiO_2 this band is not observed (Fig. 6). The Brønsted acid sites observed for the Nb₂O₅/SiO₂ system prepared by the grafting method and calcined at 473 K showed to be unstable with thermal treatment [44]. This acid site disappeared after drying at 373 K under low pressure.

The band observed at 1490 cm^{-1} , which does not disappear for the sample heated between 298 and 523 K (Fig. 6(a)–(f)), is due to the 19*a* mode and is always present for all kinds of pyridine adsorptions [38]. Physically adsorbed liquid-like pyridine 8*a* mode [10,45] is observed as a very weak band at 1580 cm⁻¹ for SiO₂ and for the samples heated at 298 and 373 K (Fig. 6(a)–(c)).

The Lewis acid site, arising from coordinatively unsaturated Nb atom, was not observed. For Nb₂O₅ grafted on SiO_2 surface (a sub-monolayer of the metal oxide on the surface with the following characteristics: surface density of 1.7 Nb atoms per nm² and average Nb-Nb distance of 0.76 nm) the Lewis acid site is observed at $1450 \,\mathrm{cm}^{-1}$ and is thermally stable up to 573 K [44]. It is possible that this band is overlapped with the 19b mode of pyridine bonded to free silanol groups through hydrogen bonding but on heating the sample at 523 K, no band assignable to pyridine adsorbed on a Lewis acid site is observed (Fig. 6(f)). The absence of Lewis acid sites is due to the method of preparation that produces niobium oxide particles with crystallite sizes about 7 nm [17]. In this case, the niobium atoms in the silica matrix are coordinatively saturated and, thus, no Lewis acid sites were detectable. It cannot be discarded the possibility that the physically sorbed water from the Lewis acid sites may not have been removed from the investigated materials calcined at

383 K, explaining why Lewis acid sites are not detected in the FT-IR studies.

4. Conclusions

The XPS study shows the existence of the metal in an ionic chemical environment formed in the Nb₂O₅/SiO₂ matrix during the sol-gel process and, probably, these species are related to Si-O-Nb bonds. The NbO_x structure in the matrix is very stable, since its local order is maintained under thermal treatment. We also could verify no change in Nb-Si length (from the second coordination sphere), confirming the good thermal stability of the Si-O-Nb linkages. On the other hand, the increase of the coordination number of the longest Nb–Nb and of the second peak from |F(r)| with distances of 2.7–3.8 Å due to the thermal treatment, is related to less dispersion of the niobium species in the matrix (formation of niobium oxide agglomerates with significant size), leading to a decrease of the specific surface area [17]. At high temperatures, Nb₂O₅ amorphous particles crystallize into nanosized dimensions (6-21 nm) depending on the metal oxide amount in the sol-gel matrices. The thermal stability of Brønsted acid sites, Nb-OH and Nb-OH-Si groups, is due to the restricted mobility of the oxide particles imposed by Si–O–Nb bond formation in the sol–gel matrix.

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